

DOCKET NO: 284119US6XPCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
KATSUTOSHI TAKAGI, ET AL. : EXAMINER: YANG, JIE
SERIAL NO: 10/564,502 :
FILED: JANUARY 13, 2006 : GROUP ART UNIT: 1793
FOR: AG BASE SPUTTERING TARGET :
AND PROCESS FOR PRODUCING THE
SAME

RESPONSE TO RESTRICTION REQUIREMENT

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

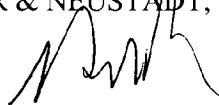
SIR:

In response to the Restriction Requirement stated in the Official Action dated February 27, 2009, Applicants elect Group I, Claims 1-6 and 9-11, drawn to a product of a silver alloy-sputtering target with uniform grain size.

Therefore, it is respectfully requested that a full examination on the merits of Claims 1-6 and 9-11 be conducted.

Respectfully submitted,

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